Amendments to the Specification:

Please amend the paragraph beginning at page 3, line 7 of the present specification as follows:

The present invention is a heating injection apparatus for vapor liquid delivery system. This apparatus implements a ~~thermostat device~~ heater to heat process gases and an inert gas purging module to isolate liquid source from other process gases, the heating injection apparatus includes an inert gas purging ~~parts~~ and ~~a thermostat device~~ the heater. The heating source of this heater can be a heating coil or infrared ray, and the temperature setting of the heater can be adjusted to meet liquid source requirement.

Please amend the paragraph beginning at page 6, line 23 of the present specification as follows:

Continuously referring to FIG.2, a carrier gas 215 before entering the gas line 245 has been heated by a ~~thermostat device~~ heater 225. The carrier gas 215 is used to carry the atomized liquid source 201 that is injected by liquid injector 205, and then the carrier gas 215 delivers the atomized liquid source 201 pass through the delivery line 250 into gas-mixing device 255. The ~~thermostat device~~ heater 225 is used to heat the carrier gas 215 to the demanded production temperature before the carrier gas 215 enters the vapor liquid delivery system. The thermostat device 225 heats the gas more efficiently, quickly and holds the gas temperature constant. And the ~~thermostat device~~ heater 225 can also maintain the temperature of vapor and prevent further condensation that caused by a temperature decrease when the carrier gas 215 is mixed with atomized liquid source 201.

Please amend the paragraph beginning at page 7, line 11 of the present specification as follows:

In this preferred embodiment of the present invention, the temperature of the carrier gas for to carry the atomized liquid source TMCTS in the delivery line 250 at a temperature no less than 350℃, but not greater than 450℃, and the preferred temperature is being 400℃. The heating source of ~~thermostat device~~ the heater 225 in this preferred embodiment of present invention can be a heating coil or an infrared ray ~~thermostat device~~ heater, and the temperature setting of the

thermostat device can be adjusted to meet the demand production requirement. In other embodiment the ~~thermostat device~~ heater can be other adjustable heating apparatus.